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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/546,174	04/11/2000	Chih-Chien Liu	JIA 462C1	4793
25235	7590 09/10/2002			
	HARTSON LLP	EXAMI	NER	
ONE TABOR CENTER, SUITE 1500 1200 SEVENTEENTH ST			SERGENT, RABON A	
DENVER, C	O 80202		ART UNIT	PAPER NUMBER
			1711	14/
			DATE MAILED: 09/10/2002	14

Please find below and/or attached an Office communication concerning this application or proceeding.

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Office Action Summary

Application No. 09/546,174

Applicant(s)

Liu et al.

Examin

Rabon Sergent

Art Unit 1711

		a sit it		
	The MAILING DATE of this communication appears of	n the cover sheet with the correspondence address		
Period f	or Reply Drtened Statutory Period for Reply is set t	O EXPIRE three MONTH(S) FROM		
THE N	MAILING DATE OF THIS COMMUNICATION. ons of time may be available under the provisions of 37 CFR 1.136 (a). In no	event, however, may a reply be timely filed after SIX (6) MONTHS from the		
- If the p - If NO p - Failure - Any rei	date of this communication. eriod for reply specified above is less than thirty (30) days, a reply within the eriod for reply is specified above, the maximum statutory period will apply and to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than three months after the mailing date of thi patent term adjustment. See 37 CFR 1.704(b).	application to become ABANDONED (35 U.S.C. § 133).		
Status				
1) 💢	Responsive to communication(s) filed on Jun 19, 20	1		
2a) 💢	·			
3) 🗆	Since this application is in condition for allowance exclosed in accordance with the practice under Ex part	ccept for formal matters, prosecution as to the merits is the Quayle, 1935 C.D. 11; 453 O.G. 213.		
Disposi	tion of Claims	the terminal control of the control		
		is/are pending in the application.		
4	a) Of the above, claim(s)	is/are withdrawn from consideration.		
5) 💢	Claim(s) 50-53, 55-58, 60, and 61	is/are allowed.		
6) 💢	Claim(s) 38-49, 54, and 59			
7) 🗆	Claim(s)			
8) 🗆	Claims	are subject to restriction and/or election requirement.		
•	ntion Papers			
9) 🔀	The specification is objected to by the Examiner.			
10)	The drawing(s) filed on is/are	a) \square accepted or b) \square objected to by the Examiner.		
10/-	Applicant may not request that any objection to the dr	awing(s) be held in abeyance. See 37 CFR 1.85(a).		
11)	The proposed drawing correction filed on	is: a) \square approved b) \square disapproved by the Examiner.		
,_	If approved, corrected drawings are required in reply to			
12)	The oath or declaration is objected to by the Examin			
Priority	under 35 U.S.C. §§ 119 and 120			
13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).				
a) [☐ All b)☐ Some* c)☐ None of:			
	1. \square Certified copies of the priority documents have	e been received.		
2. Certified copies of the priority documents have been received in Application No				
	application from the International Burea	ocuments have been received in this National Stage au (PCT Rule 17.2(a)).		
_	see the attached detailed Office action for a list of the			
14) X	•			
a) [priority under 35 U.S.C. §§ 120 and/or 121.		
	Acknowledgement is made of a claim for domestic	priority under do dictor 33 120 cm. is 12.		
	nent(s) / lotice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper No(s).		
1) Motice of fieldiness offer (1.10 co.)		Notice of Informal Patent Application (PTO-152)		
_	oformation Disclosure Statement(s) (PTO-1449) Paper No(s).	6) Other:		

Application/Control Number: 09/546,174

Art Unit: 1711

1. The disclosure is objected to because of the following informalities: The discussion of figure 4 at page 12, line 26+ of the specification is confusing, because reference is made to protective layer 26; however, figure 4 does not specify a layer identified by "26".

Appropriate correction is required.

- 2. The terminal disclaimer filed on March 12, 2002 disclaiming the terminal portion of any patent granted on this application which would extend beyond the expiration date of U. S. Patent 6,117,345 has been reviewed and is accepted. The terminal disclaimer has been recorded.
- 3. Claims 38-49 are rejected under 35 U.S.C. 112, first paragraph, because the specification, while being enabling for methods wherein the gaps are substantially filled with dielectric material by the step of high density plasma chemical vapor deposition, does not reasonably provide enablement for methods wherein the deposition step fails to substantially fill the gaps. The specification does not enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to use the invention commensurate in scope with these claims.

The deposition steps of claim 42 does not require that the dielectric material substantially fill the gaps; however, this is a central objective of applicants' invention. Contrary to applicants' response, the section of the specification cited by applicants supports the examiner's position that the gaps be substantially filled. A review of figure 4 indicates that the dielectric material is deposited within the gaps up to the level of layer 26; at this point, according to the figure, the gaps are, in fact, substantially filled.

Application/Control Number: 09/546,174

Art Unit: 1711

Furthermore, applicants have provided no guidance with respect to what other deposition processes may be used in lieu of high density plasma chemical vapor deposition.

4. Claims 38-49 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

It is unclear how "based" is to further limit or define "plasma" or "process".

- 5. Claims 38-49 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. Despite applicants' response, the specification provides no guidance with respect to what is meant by a "plasma based process". Furthermore, in the absence of such guidance or definition, the language, "... a plasma based process having both an etching component and a deposition component", constitutes new matter.
- 6. Claims 38-49 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. Despite applicants' response, applicants' have failed to provide enablement with respect to what processes are encompassed by "plasma based process".
- 7. Claims 54 and 59 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to enable one skilled in the

Application/Control Number: 09/546,174 Page 4

Art Unit: 1711

art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. Firstly, with respect to claim 54, applicants have failed to provide enablement with respect to the use of a generic "silicon material" as a cap layer. Applicants have failed to teach that all compounds that fall within the scope of silicon materials may be used as a cap layer. With respect to claim 59, applicants have failed to provide enablement for having all corners of the rectangular shape etched away. The specification provides enablement only for the "upper corners" being etched away.

8. Claim 54 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

There is an omission within the first word of the claim.

- 9. Claims 38-49 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. Clear support has not been found for the subject matter of the claims. Applicants are required to indicate where clear support exists for the subject matter of the claims.
- 10. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL.** See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

Application/Control Number: 09/546,174

Art Unit: 1711

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication should be directed to R. Sergent at telephone number (703) 308-2982.

RABON SERGENT RIMARY EXAMINER

R. Sergent

September 8, 2002